



ID de Contribution: 32

Type: Poster

## Improvement robustness up to 400°C of the passivation of c-Si wafers by p-type a-Si:H thanks to ion bombardment

*mardi 10 mai 2016 10:15 (20 minutes)*

a-Si:H/c-Si heterojunction solar cells have reached record efficiencies of 24.7% (22% in industry) [1]. The passivation of c-Si in silicon heterojunction solar cells is the key to achieve a high-efficiency. The abrupt discontinuity in the crystal structure at the amorphous/crystal interface induces a high density of dangling bonds, thus creating a large density of defects induced energy levels in the bandgap. This defects are re-combination center for the electron-hole pairs generated in c-Si during the illumination. Several dielectric layers can be used to passivate n-type and p-type wafers, such as thermally grown SiO<sub>2</sub>, PECVD a-SiN<sub>x</sub>:H, Al<sub>2</sub>O<sub>3</sub> or a-Si:H. The most versatile passivation layer is a-Si:H [2], it is effective both for p-type and n-type wafers. In addition, this process has a low thermal budget since the deposition is made below 200°C. The drawback of this passivation layer, in particular when p-doped, does not withstand temperatures above 200°C [3]. However, in order to have a good electrical contact, a TCO layer with good optical and electrical quality as well as metal electrodes with good ohmic contact, annealing at temperatures up to 500°C is desirable [4]. We homogeneously implanted argon ions, with IRMA implanter, solar cell precursors synthesized at LPICM. We irradiated samples with energies between 5 and 30 keV, to control the depth at which we are creating defects. By varying the fluence between 1012 Ar.cm<sup>-2</sup> and 1015 Ar.cm<sup>-2</sup> we control the concentration of defects created. We show that irradiation with an energy of 5 keV with a fluence of 1015 Ar.cm<sup>-2</sup> does not degrade significantly the solar cell precursor. The effective lifetime of the minority carriers measured using a Sinton Consulting (WT-120) from 2.6 ms to 2.4 ms after irradiation. On the other hand an energy of 10 keV with a fluence of 1014 Ar.cm<sup>-2</sup> or an energy of 17 keV with a fluence of 1012 Ar.cm<sup>-2</sup> is sufficient to degrade the lifetime of more than 85% [5]. Following the irradiations, the solar cells have been annealing in a controlled atmosphere at different temperatures. We show that annealing heal the defects introduced by irradiation. Moreover, lifetime after irradiation and annealing above the as-deposited lifetime can be obtained. Finally, we show that ion irradiation allows to maintain a good lifetime above 1 ms after annealing our solar cell precursors up to 380°C.

(These results are part of a patent deposited September 7, 2015).

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**Classification de Session:** Poster session

**Classification de thématique:** Accelerator Physics